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Deposition of Cu-doped PbS thin films with low resistivity using DC sputtering



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ABSTRACT

Investigation of the electrical resistivity of Cu-doped PbS thin films has been carried out. The films were prepared using a DC sputtering technique. The doping was achieved by introducing the Cu dopant plate material directly on the surface of the PbS sputtering target plate. SEM-EDX data shows the Cu concentration in the PbS film to be proportional to the Cu plate diameter. The XRD pattern indicates the film is in crystalline cubic form. The Hall effect measurement shows that Cu doping yields an increase in the carrier concentration to $3.55 \times 10^{19} \, \mathrm{cm}^{-3}$ and a significant decrease in electrical resistivity. The lowest resistivity obtained was $0.13 \, \Omega \mathrm{cm}$ for a Cu concentration of 18.5%. Preferential orientation of (111) and (200) are during deposition.

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Introduction

Lead sulfide (PbS) is a 17-known semiconductor material with interesting properties. It has a direct and narrow bar 24 p of 0.41 eV at room temperature [1]. PbS has high absorbance in the UV-Vis spectral range and high transmittance in the infrared spectral region of 1–3 µm [2], allowing its use in infrared detectors. This material also h 16 pplications in other opto-electrical devices such as solar cells. The electrical properties of PbS thin films can be tailored by introducing dopants into the material and depositing the film on various 10 strates, such as glass [3,4], silicon [5], and glass/silicon [6] by techniques such as chemical bath deposition (CBD). Akmedov [7] prepared PbS films using a simple chemical deposition.

The dopants Zn [8] and Sr [423 ve been incorporated into PbS using CBD, and Ba using the successive ionic layer adsorption and reaction (SILAR) technique [10]. Cheraghizade et al. [11]

(CVD) for photovoltaic devices. PbS nanocrystal-doped SiO₂ films were prepared using sputtering [12] and the material structure and properties were investigated. Also, Bi-doped PbS quantum dots were prepared for 7 otovoltaic devices [13].

Cu-doped PbS thin films have also been studi 2 by many

prepared a Zn-doped PbS thin fil 28 sing chemical vapor deposition

researchers for various applications. Preparations 015 u-doped PbS thin films by CBD have been reported [14-17]. Zheng et al. [14] prepared Cu-doped PbS thin films to study the low resistivity of the material. The resu 8 obtained has been encouraged our work to prepare more robust thin films with low resistivity using a DC sputtering technique. This was done by introducing Cu plate as a dopant material. Beside, a novel method introduced for doping process using a dopant plate putting directly on the surface of the material target. By using this technique other dopant materials such of Fe could also be introduced with a simple way and practical. By comparing the work done using sputtering technique to the other technique of CBD, the sputtering technique produces more robust PbS film deposition and relatively faster in deposition time. In the present study, we 2 prove the investigation for the structural and morphological properties of PbS and Cu-doped PbS thin films using SEM-EDX and investigate the electrical properties using a Hall effect technique. The interesting properties observed from the material is its lower resistivity film compare the other works

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published previously that will be reported. Also, the detail explanation of the doping effect introduced to the material.

Experimental

Synthesis

PbS thin film deposition was prepared using a DC sputtering technique. The PbS target plate was 99.9% purity (QS Rare Element) with 2.0 in. diameter and 0.12 in. thickness. The dopant plate of Cu (99.9% purity, Goodfellow) with 0.5 mm thickness was put onto the PbS target plate at the center 22 tion. Various Cu concentrations (wt%) were incorporated into the PbS thin films. Samples 0, 1, 2, 3, 4 and 5 denote the samples with Cu plate diamater and concentrations as tabulated in Table 1. During the sputtering process, the vacuum pressure was maintained at 2.0×10^{-2} Torr, the distance between target and substrate was 3 cm. The power of sputtering process was supplied for 20 Watt. A glass microscope slide with deposition area of 1.0×2.5 cm² was used as the substrate. All samples were deposited for 30 min at the same condition. The substrate was placed at the anode (top position), while the target material was at the cathode (bottom position) as shown in Fig. 1. This orientation was adjusted to minimize contaminant deposition

Table 1
Some parameters of thin film deposition.

Sample no	Plate diamater (mm)	Cu concentration (wt%)
0	_	0.0
1	5.0	2.8
2	7.5	4.0
3	10.0	10.5
4	15.0	18.9
5	20.0	31.2



Fig. 1. The photograph of PbS target and Cu dopant plate in the vacuum chamber.

during the sputtering process. The distance between the anode and cathode was adjusted to 3 cm.

Methods

Material structures of the film were characterized using X-ray diffraction (XRD) with CuK_{α} radiation source (λ = 1.54 Å) and 30 morphology of film was characterized using SEM-EDX. The Hall ect measurement was also carried out in order to investigate electrical properties of the films, such of carrier concentration, mobility, and resistivity.

Results and discussion

The samples were measured using SEM-EDX to study the morphological surface and to find the elemental composition (Pb, S, Cu) of the films (Figs. 2a and 2b). As we can see in Fig. 2a from the SEM measurement, the undoped PbS deposition has homogeneous surface morphology and smooth with very good grain boundaries. The average grain size is calculated and found to be 35 nm. The results indicate successful doping of PbS by Cu using the sputtering method described. The increase in diameter of the dopant plate results in an increase in concentration of dopant in the PbS thin film. This thin film preparation method is considerably new for DC sputtering, particularly for Cu as a dopant material. Common method used was done by mixing the target material with the doping material prior to the deposition using a special method that needs additios work leads to time consuming, impractical and costly.

XRD patterns of the Cu-doped PDS thin films are shown in Fig. 3. The calculated diffraction plane (Miller index) refers to the index printed on the axis of the database (JCPDS, Card No 05-0592). The Bragg peaks obtained were in good agreement with the database, indicating cubic crystalline structure. The peak intensities observed from the diffraction planes (1 1 1) and (2 0 0) change with the elemental composition of each film. For Cu concentrations of 10.5% and 18.9%, the peaks observed at (1 1 1) and (2 0 0) are relatively sharp, indicating high crystallinity. Thus, these Cu concentrations are preferential for film deposition. At the doping concentration of 31.2%, the Bragg peaks become broadened, indicating

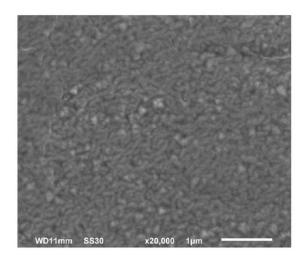


Fig. 2a. Morphological image obtained from SEM for PbS thin film sample.

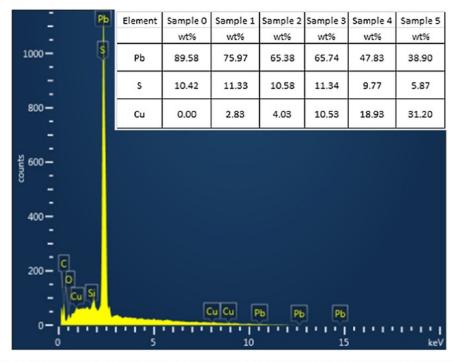


Fig. 2b. Representative EDX data (Sample 1) and elemental compositions (inset table) of each Cu-doped PbS thin film sample.

that the crystal structure contained defects or became less crystalline.

The texture coefficient (*TC*) of preferential direction was deduced from the observed Bragg peaks (F27). This coefficient indicates the degree of crystallinity formed during the deposition of the thin film, and is calculated using the following equation [15]:

$$TC = \frac{I(hkl)/Io(hkl)}{\frac{1}{N} \sum_{N} \binom{I(hkl)}{Io(hkl)}}$$
(1)

where, *I*(*hkl*) is the measured intensity of (*hkl*) plane of the sample, *Io* (*hkl*) is the standard intensity of (*hkl*) plane based on the powder diffraction file (JCPDS) card, and *N* is the number of diffraction peaks considered in the analysis. From the calculation, the *TC* at the diffraction plane of (1 1 1) and (2 0 0) appears more stable with an increase of Cu concentration from 10.5 to 18 26 Higher Cu concentrations appear to reduce crystallinity of the thin films, as can be seen from the XRD pattern. An interesting phenomenon observed is that with the relatively stable growth (Cu doping concentration of 18.9%), a minimum resistivity is achieved.

The parrier concentration in the PbS films increases to a maximum as the Cu dopant concentration increases from 2.8 to 18.9% (solid data points in Fig. 5a). Then, fo 21.2% Cu dopant, the carrier concentration decreases. This trend was also observed by Zheng et al. [14] and Toua 1 t al. [15]. The increase in carrier concentration occurs because the substitution of 1 ions for Pb ions induces more vacancies [14]. This increase is attributed to the mid-gap state created by Cu doping that traps and screens electrons, 10 explained by Huang et al. [18]. With further doping, excess Cu atoms can not occupy lattice sites. They form neutral defects that

become <u>ineffective</u> as carriers, leading to a decrease in carrier concentration. As can be seen in Fig. 5a, the maximum value of carrier concentration is $3.55 \times 10^{19} \, \text{cm}^{-3}$, achieved at a Cu concentration of 18.9%.

The increase in Cu doping (up to 31.2%) 1 elds fluctuations of carrier mobility ranging from around 148 cm²/V·s down to 16 cm²/V·s (open data points in Fig. 5b), with an overall decreasing tend. Similarly, a decrease in carrier mobility from around 110 cm²/V·s down to 6 cm²/V·s was observed by Zheng et al. [14] for Cu concentrations increasing up to 8%. Regarding carrier mobility, the highest value is observed in the undoped PbS film. The increased mobility is assumed to be due to the Coulombic interactions among the carriers that form electron traps and screens, as mentioned before. The carriers introduce a longer, mean-free time of collision that increases mobility. Meanwhile, the decreased mobility at higher Cu concentration is due to the Cu ions forming ineffective neutral defects. This phenomenon can be attributed to scattering and defects caused by excess carriers [18]. The defects in the crystal stru 20 e can be observed as broadened peaks in the XRD patterns (Fig. 3).

The increase in Cu dopant concentration up to 18.9% in the PbS films is followed by a decrease in resistivity. A further increase in Cu dopant concentration yields an increase in resistivity. These effects show that introducing Cu doping to PbS films changes the electrical properties of the material significantly. A Cu concentration of 18.9% achieves a minimum resistivity value of 0.13 Ω cm (Fig. 5b). A comparison of resistivity values from previous works is shown in Table 2. In this current work, we report a relatively low resistivity, achieved by using a DC sputtering technique for Cu-doped PbS thin film formation. Beside, the simple method of doping was introduced in the sputtering deposition technique.

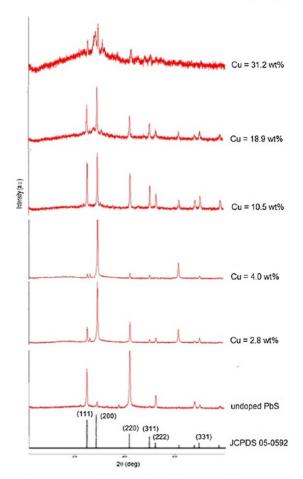


Fig. 3. XRD patterns **obtained** for each Cu-doped PbS thin film sample. The calculated diffraction plane (Miller index) refers to the index printed on the axis of the database.

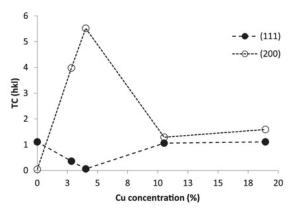
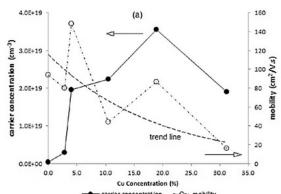


Fig. 4. TC for (1 1 1) and (2 0 0) directions in Cu-doped PbS thin films.

Conclusion

Cu-doped PbS thin films have been successfully prepared using a DC sputtering technique. The film deposition has good crys-



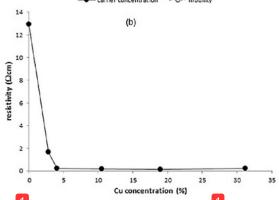


Fig. 5. Effect of Cu doping concentration in PbS films on (a) carrier concentration and mobility, and (b) resistivity.

Table 2
Resistivity values for Cu-doped PbS thin films obtained from the literature.

Deposition technique	Resistivity (Ω·cm)	Reference
DC sputtering	0.13	current work
CBD	0.15	Zheng [14]
CBD	0.16	Touati [15]
CBD	4.1	Pérez-García [16]

tallinity, as shown by the XRD measurement. From Hall measurements, it was shown that the carrier concentration has a maximum value of $3.55 \times 10^{19} \, \text{cm}^{-3}$ at 18.9% dopant concentration. The increase of Cu concentration is followed by an increase of carrier concentration until the maximum value, after which it decreases. In comparison to values in the literature, a relatively lowest resistivity of $0.13 \, \Omega \text{cm}$ was obtained with an $18.9\% \, \text{Cu}$ concentration. 29 use of Cu as a dopant is an effective method of improving the electrical resistivity of PbS thin films for device applications.

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